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(12) **United States Design Patent**  
**Nakamura et al.**

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(54) **COSMETIC MASK**

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(\*\*) Term: **15 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (13) Cl.** ..... **28-03**

(52) **U.S. Cl.**  
USPC ..... **D28/7**

(58) **Field of Classification Search**  
USPC ..... D28/7, 8, 99; D29/108; D21/660  
CPC ..... A45D 44/002; A45D 2200/1009  
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a cosmetic mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a cosmetic mask showing our new design;  
FIG. 2 is a front view thereof, the rear view being a mirror image thereof;  
FIG. 3 is a left side view thereof;  
FIG. 4 is a right side view thereof;  
FIG. 5 is a top view thereof; and,  
FIG. 6 is a bottom view thereof.

**1 Claim, 3 Drawing Sheets**

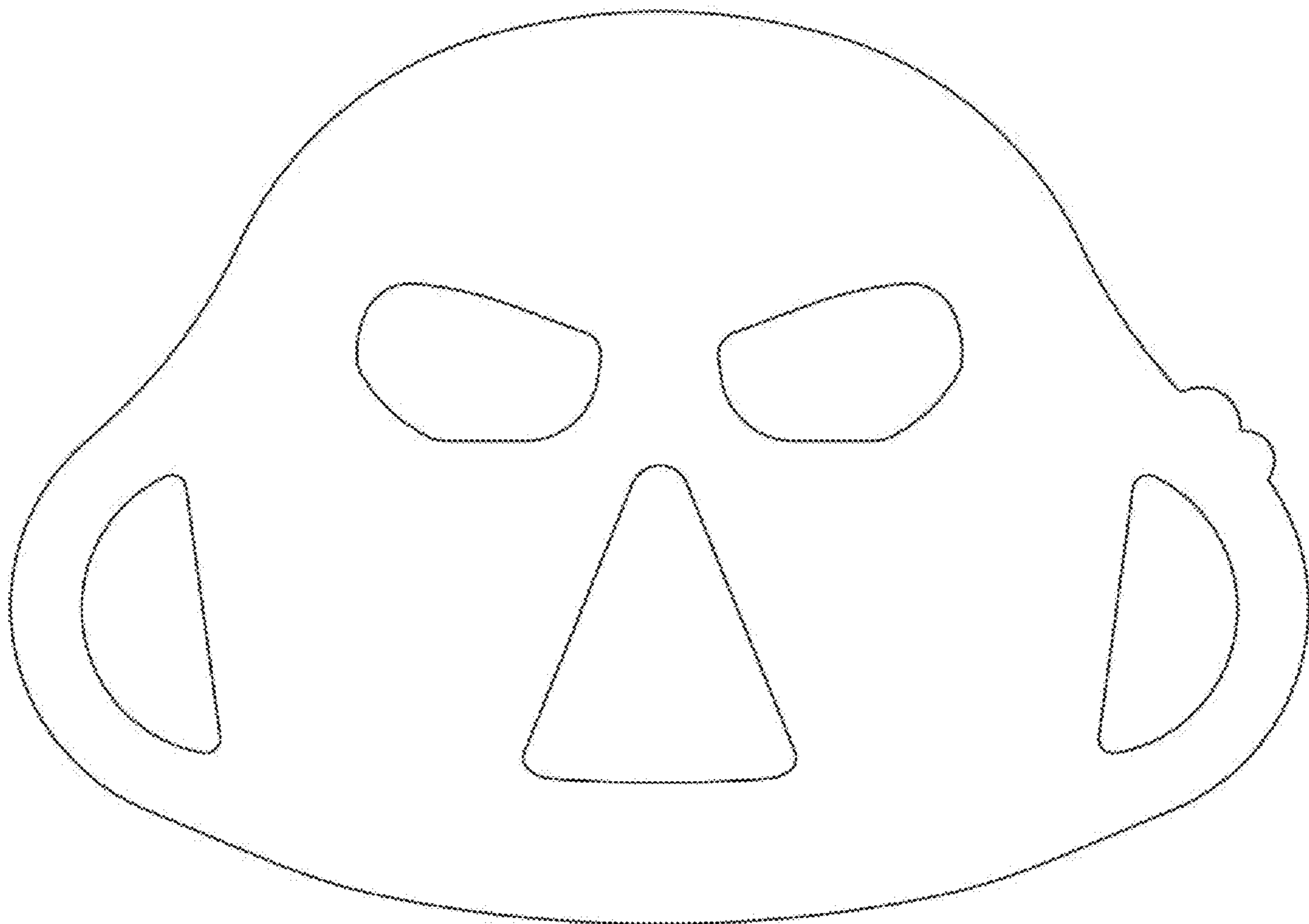




FIG. 1

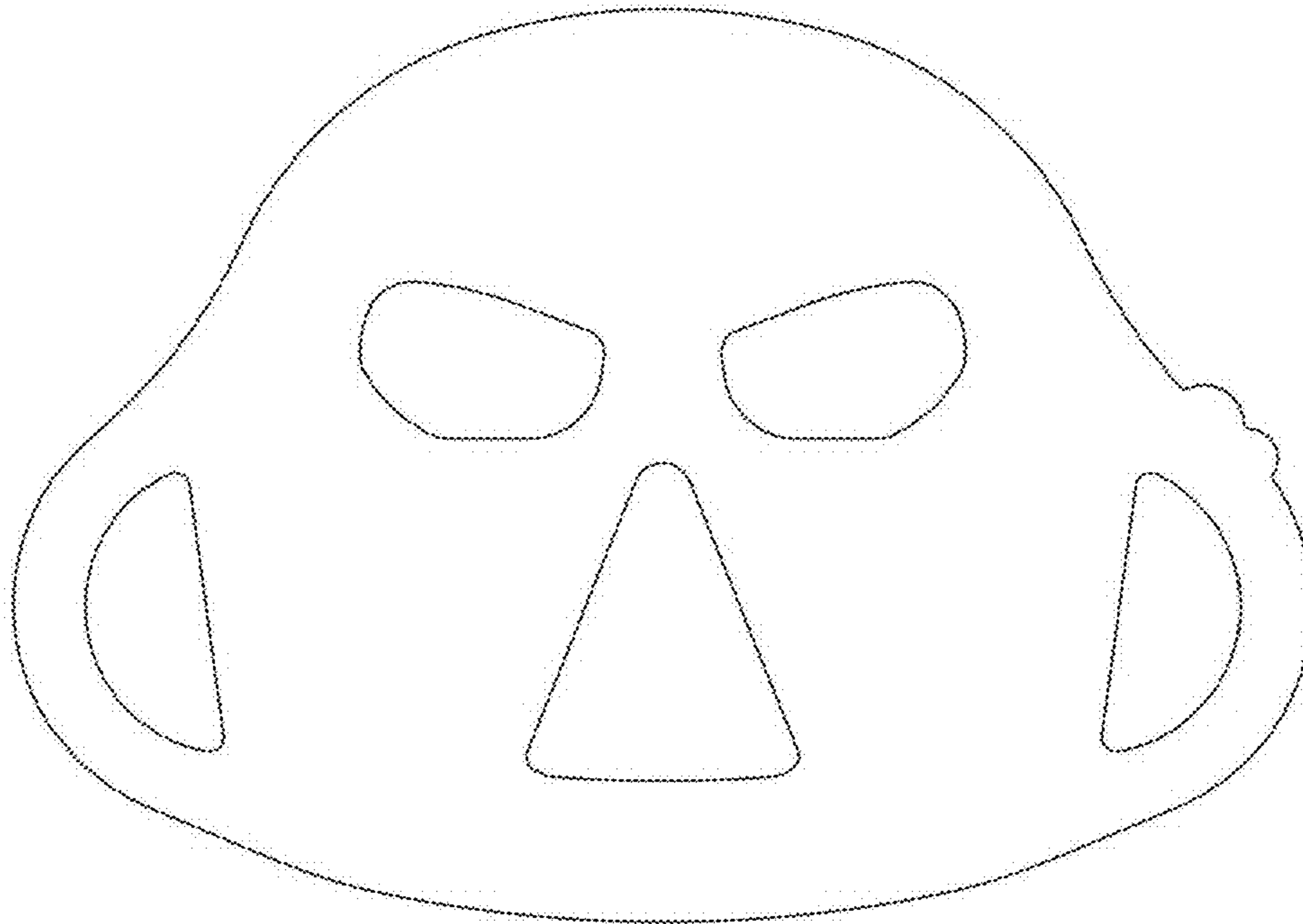


FIG. 2

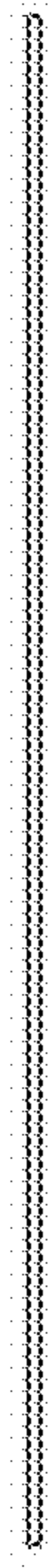
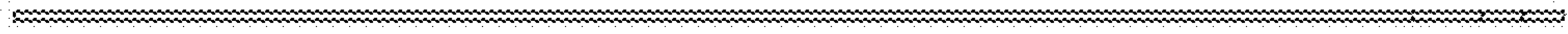


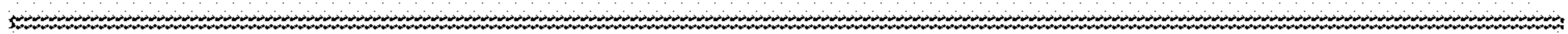
FIG. 3



FIG. 4



**FIG. 5**



**FIG. 6**